

MOCVD LAB IN ENGINEERING CENTERS BUILDING

16C1Y



This project remodels suite 206d in the Engineering Centers Building for a new facility recruit involved in Metal Organic Chemical Vapor Deposition (MOCVD) used in the manufacturing of computer chips. It will be an H5 hazardous occupancy with intensive equipment needs.

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BUDGET		
Total	\$756,000	
Construction	\$608,000	
Design	\$60,800	
Mgt.	\$27,000	
Contingency	\$60,800	
Equipment	\$0	
Other Fees	\$0	
Funding Sources:		
Gifts & Grants	\$756,000	

TIMELINE	
A/E Selection	04/2016
35% Design Report	05/2016 - 07/2016
Construction Documents	07/2016 - 08/2016
Bid Date	12/2016
Construction	02/2017 - 11/2017
Substantial Completion	11/2017
Occupancy	11/2017

KEY STAKEHOLDERS				
Occupants	College of Engineering			
User Reps	Sharon Devenish			
UW PM	Pete Heaslett			
DFD PM	Doug Schorr			
A/E	KEE Architects			
Design Arch.	N/A			
Landscape Arch.	N/A			
Structural Engr.	N/A			
General Contractor	Miron Construction			
Plumbing	Hooper Corp.			
Mechanical	Н&Н			
Fire Protection	Ahern			
Electrical	Forward Electric			

AREA DATA		
GSF	N/A	
ASF	N/A	
Efficiency	N/A	
Construction \$/GSF	N/A	
Total Project \$/GSF	N/A	